## AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions and listings of claims in the application:

## LISTING OF CLAIMS:

1. (currently amended): A coating composition for forming a silica-containing film comprising (A) a hydrolyzate and/or partially condensed product of a compound represented by the following general formula (I) and a compound represented by the following general formula (II):

$$\begin{array}{c} (R^1)n \\ I \\ Si \longrightarrow (OR^3)_{4\text{-}(n+m)} \\ I \\ (R^2)m \end{array} \qquad (I)$$

wherein  $R^1$  represents a hydrogen atom, an alkyl group having 1 to 18 carbon atoms or an aryl group having 6 to 14 carbon atoms;  $R^2$  represents an organic group having an unsaturated bond and 2 to 12 carbon atoms;  $R^3$  represents an alkyl group having 1 to 6 carbon atoms; n is an integer ranging from 0 to 2; m is an integer ranging from 1 to 3, provided that n and m are selected such that they satisfy the following relation:  $0 \le n + m \le 3$   $1 \le n + m \le 3$ ; and

$$(R^4)p$$
 $Si$ 
 $(OR^6)_{4-(p+q)}$ 
 $(II)$ 
 $(R^5)q$ 

wherein R<sup>4</sup> represents an alkyl group having 1 to 18 carbon atoms or an aryl group having 6 to 14 carbon atoms; R<sup>5</sup> represents a hydrogen atom; R<sup>6</sup> represents an alkyl group having 1 to 6

carbon atoms; and p and q are integers selected in such a manner that they satisfy the following relation:  $0 \le p + q \le 3$ ;

- (B) a solvent for coating; and
- (C) at least one member selected from the group consisting of a void-forming solvent, a compound having a polyalkylene oxide structure and hollow polymer fine particles.
- 2. (currently amended): The coating composition for forming a silica-containing film as set forth in claim 1, wherein the component (C) is comprises a void-forming solvent.
  - 3. (canceled).
- 4. (currently amended): The coating composition for forming a silica-containing film as set forth in claim 1, wherein the component (C)-is comprises hollow polymer fine particles.
- 5. (currently amended): A method for forming a silica-containing film comprising the steps of applying a coating composition for forming a silica-containing film as set forth in any one of the foregoing claims 1 to 4 1, 2 and 4 onto a base material and then drying the coated layer.
- 6. (currently amended): A silica-containing film obtained from a coating composition for forming a silica- containing film as set forth in any one of the foregoing claims-1 to 41, 2 and 4.